

Attorney Docket: 081468-0307120  
Client Reference: P-1756.000-US

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:  
VAN DER SCHAAR *et al.*

Confirmation No.: 3339

Application No.: 10/730,254

Examiner: Hartman Jr., Ronald D.

Filed: December 9, 2003

Group Art Unit: 2121

Title: LITHOGRAPHIC APPARATUS, METHOD OF DETERMINING A MODEL  
PARAMETER, DEVICE MANUFACTURING METHOD, AND DEVICE  
MANUFACTURED THEREBY

REQUEST FOR CORRECTED FILING RECEIPT

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

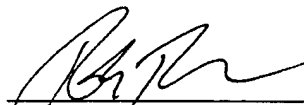
Attached is a copy of the Filing Receipt received from the U.S. Patent and Trademark Office in the above application, on which the following error has been corrected.

The address of the Assignee listed as "LA Veldhoven, NETHERLANDS" should be listed as --Veldhoven, NETHERLANDS--.

It is respectfully requested that the records of the U.S. Patent and Trademark Office be corrected and that a corrected Filing Receipt be issued immediately.

Respectfully submitted,

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## UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE  
 United States Patent and Trademark Office  
 Patent Center  
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APPL NO	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/730.254	12/09/2003	1756	936	081468-0307120	2	22	3

CONFIRMATION NO. 3339

00909  
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UPDATED FILING RECEIPT



\*OC000000012783224\*

Date Mailed: 05/26/2004

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Filing Receipt Corrections, facsimile number 703-746-9195. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

## Applicant(s)

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## Assignment For Published Patent Application

ASML NETHERLANDS B.V., ~~LA Veldhoven~~, NETHERLANDS;  
Veldhoven

Domestic Priority data as claimed by applicant

Foreign Applications

If Required, Foreign Filing License Granted: 03/12/2004

Projected Publication Date: 06/09/2005

Non-Publication Request: No

Early Publication Request: No

## Title

Lithographic apparatus, method of determining a model parameter, device manufacturing

method, and device manufactured thereby

**Preliminary Class**

430

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Title 35, United States Code, Section 184  
Title 37, Code of Federal Regulations, 5.11 & 5.15**

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